

U.S. Department of Commerce Patent and Trademark Office Atty. Docket No. | Serial No. | 27391/US588 | 10/617,560 | Applicant

INFORMATION DISCLOSURE STATEMENT

Nakayama
Filing Date Group
7/11/03

U.S. PATENT DOCUMENTS						
*Examiner Initials	Document Number	Issue Date	Name	Class	Subclass	Filing Date if Appropriate
KST	5,175,658	12/29/92	Chang et al.	360	103	
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Or	59174508 A	10/03/84	Japan			Abstract	
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1	62145646 A	06/29/87	Japan			Abstract	
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	OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)
BI	New Diamond, Japan New Diamond Forum 11, October 1988, Vol. 4, No. 4, pp. 14-17
RI	"Bias Effect on the Formulation of Carbon Films by RF-Plasma CVD", Nakayama et al., Journal of Ceramic Society of Japan Int. Edition, Vol. 98, 1990, pp. 597-600

Examiner R.S. TWM	Date Considered 9/	05			
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